Attorney Docket No.: Q78082

Application No.: 10/575,365

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions and listings of claims in the

application:

LISTING OF CLAIMS:

1. (currently amended): A flip-chip-type gallium nitride compound semiconductor

light-emitting device comprising a substrate, an n-type semiconductor layer, a light-emitting

layer, and a p-type semiconductor layer,

wherein a negative electrode is provided on said n-type semiconductor layer, and a

positive electrode is provided on said p-type semiconductor layer;

the n-type semiconductor layer, the light-emitting layer, and the p-type semiconductor

layer being successively provided atop said substrate in this order and being composed of a

gallium nitride compound semiconductor,

wherein said positive electrode has a three-layer structure comprising an ohmic electrode

layer composed of rhodium which is in contact with said p-type semiconductor layer, an

adhesion layer composed of titanium which is provided on said ohmic electrode layer and has a

thickness of 1000 Å to 3,000 Å, and a bonding pad layer provided on said adhesion layer and

being composed of a metal selected from the group consisting of gold, aluminum, nickel, and

copper, or composed of an alloy containing at least one of these metals;

wherein the bonding pad layer is provided atop a portion of the ohmic electrode layer,

wherein said portion is less than the entirety of the ohmic electrode layer, and that wherein the

adhesion layer has the same dimension as the bonding pad layer.

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Claims 2-3. (canceled).

4. (previously presented): A flip-chip-type gallium nitride compound semiconductor

light-emitting device according to claim 1, wherein said ohmic electrode layer has a thickness of

100 Å to 3,000 Å.

5. (original): A flip-chip-type gallium nitride compound semiconductor light-

emitting device according to claim 4, wherein said ohmic electrode layer has a thickness of 500

Å to 2,000 Å.

6. (previously presented): A flip-chip-type gallium nitride compound semiconductor

light-emitting device according to claim 1, wherein said bonding pad layer has a thickness of at

least 1,000 Å.

7. (original): A flip-chip-type gallium nitride compound semiconductor light-

emitting device according to claim 6, wherein said bonding pad layer has a thickness of 3,000 Å

to 5,000 Å.

8. (previously presented): A flip-chip-type gallium nitride compound semiconductor

light-emitting device according to claim 1, wherein said bonding pad layer is composed of gold.

9. (currently amended): A positive electrode for use in a gallium nitride compound

semiconductor light-emitting device, wherein said positive electrode has a three-layer structure

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comprising an ohmic electrode layer composed of rhodium which is brought into contact with a

p-type semiconductor layer of said gallium nitride compound semiconductor light-emitting

device, an adhesion layer composed of titanium which is provided on said ohmic electrode layer

and has a thickness of 1000 Å to 3,000 Å, and a bonding pad layer provided on said adhesion

layer, said bonding pad layer being composed of a metal selected from the group consisting of

gold, aluminum, nickel, and copper, or composed of an alloy containing at least one of these

metals; wherein the bonding pad layer is provided atop a portion of the ohmic electrode layer,

wherein said portion is less than the entirety of the ohmic electrode layer, and that wherein the

adhesion layer has the same dimension as the bonding pad layer.

Claims 10-11. (canceled).

12. (previously presented): A light-emitting diode comprising a flip-chip-type

gallium nitride compound semiconductor light-emitting device according to claim 1.

13. (canceled).

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